Valence band structure of AlN probed by photoluminescence

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Deep ultraviolet photoluminescence (PL) was employed to probe the valence band structure of AlN epilayers grown by metal organic chemical vapor deposition on c-plane sapphire substrates. At 10 K, in addition to the dominant emission peak at 6.050 eV polarized in the E||c direction, we observed two additional emission peaks at 6.249 and 6.262 eV polarized in the E⊥c direction. These two emission lines are assigned to the recombination of free excitons related to the B and C valence bands. A more comprehensive picture of the valence band structure of AlN is thus directly obtained from the PL measurements. © 2008 American Institute of Physics.

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AlN has the widest direct band gap (~6.1 eV) among the nitride semiconductors and offers a continuous band-gap variation through the alloying and heterostructure design with GaN and InN. It is an ideal material for the development of UV-light sources (detectors) operating in the wavelength range down to 200 nm. The electrical and optical properties of semiconductors are mainly determined by the electronic band structure near the Γ point. Information regarding the band structure of AlN is fundamentally important for the understanding of the basic properties of AlN and its device applications. Due to an increasing interest in AlN in recent years, several theoretical and experimental studies on the fundamental optical properties of AlN have been reported.

The valence band of wurtzite (WZ) III-nitrides with Γ₁₅ symmetry splits into three levels (A, B, and C) valence bands in the order of increasing emission energies. Hexagonal symmetry of the WZ structure induces crystal-field splitting into twofold degenerate Γ₆ state and nondegenerate Γ₁ state. Spin-orbit interaction further splits Γ₆ state into Γ₀ and Γ₂ states. Magnitude and nature of crystal-field splitting parameter (Δ_Cr) in WZ AlN depend on deviations of its lattice constants’ ratio c/a and internal a parameter from their values for an ideal WZ structure. AlN has a large negative Δ_Cr, so that the energy level of Γ₁ is higher than that of Γ₀. By examining GaN and all other semiconductors with WZ structure, we notice that Δ_Cr is generally small and positive so that the energy level of Γ₀ is always higher than that of Γ₁. This unusual ordering of the valence bands gives rise to unique optical properties of AlN. The recombination of excitons associated with the A, B, or C valence bands has different probabilities for different polarizations of absorbed or emitted light. The emission spectrum in AlN has a dominant II-polarized (E||c) emission, in contrast to the dominant σ polarized (E⊥c) emissions in GaN. These optical polarization properties may be exploited for polarization filtering, polarized emission in AlN based light emitting diodes, polarization-sensitive photodetectors, and AlN based TM mode laser in the future.

The A exciton transition in AlN was experimentally observed by photoluminescence (PL) and cathodoluminescence (CL) measurements. There were also several reports from optical reflectance measurements on the observation of A, B, and C excitonic transitions. However, the B and C excitonic transitions have never been directly observed by PL measurement. Recently, by increasing the thickness of the epilayers, we have achieved AlN epilayers with a reduced dislocation density. The fabricated metal-semiconductor-metal photodetectors based on these AlN epilayers exhibited a peak responsivity at 200 nm with a sharp cutoff wavelength at 207 nm and extremely low dark currents (~50 fA at 300 V). In this work, we report on the studies of the valence band structure of AlN based on the observation of three well resolved excitonic emission peaks in high quality AlN epilayers directly probed by polarization resolved PL.

AlN epilayers with a thickness of 4 μm were grown on c-plane sapphire substrates by metal-organic chemical vapor deposition. Deep UV PL measurement was employed to probe the excitonic transitions and the polarization of emitted light. The excitation light source was a frequency quadrupled Ti-sapphire laser (with more than 90% vertical polarization), 76 MHz repetition rate, 100 fs pulse width, and photon energy set around 6.29 eV. The collected emission was dispersed by a 1.3 m monochromator. The sample was held in a stage with its c axis (c) pointing in the vertical direction perpendicular to the sample surface and the excitation laser was incident at very small angle with respect to the sample surface, as illustrated in the inset of Fig. 1(a). A polarizer was used in front of the slit of the monochromator to resolve E||c (II) or E⊥c (σ or α) components.

Figure 1 compares the low temperature PL spectra of an AlN epilayer collected for the emitted light with electric field component (E) (a) parallel (E||c) and (b) perpendicular (E⊥c) to the c axis. The intensity of the emission peak at 6.050 eV for the E||c polarization is much stronger than that for the E⊥c polarization. The emission lines at 5.95, 5.84, and 5.73 eV in Fig. 1(b) marked as 1 LO, 2 LO, and 3 LO are one, two, and three phonon replicas of the dominant 6.05 eV emission line in AlN with a LO phonon energy of about 110 meV. The peak at 6.18 eV is the Raman line due to the excitation laser set at 6.29 eV. The dominant emission line at 6.05 eV has a linewidth of about 29 meV. Previous theoretical calculation showed that the A valence band related band-edge transition in AlN is allowed only for the E||c polarization and almost forbidden for the E⊥c polarization. Therefore, spectral peak position, line width, and observed...
The results seem to suggest that the effects of strain on valence bands are less pronounced than that on the -exciton. The observed peak at 6.249 eV in Fig. 1, which is in contrast to the stress-free AlN due to a compressive strain, while a blueshift for the AlN based on the present experimental data. How- ever, excitons associated with the A, B, and C valence bands have almost the same binding energies in GaN. Therefore, we assume that the B and C excitons in AlN have the same binding energy as that of the A exciton. This gives the band gap of AlN to be (6.249+0.080)=6.329 eV and (6.262 +0.080)=6.342 eV for the B and C valence bands, respectively.

Based on the results shown in Fig. 1, we have constructed in Fig. 3 the energy band structure of AlN near the point. The corresponding optical transitions are illustrated by downward arrows. Polarization properties of emitted light are different depending on which of the valence bands are involved in the recombination. Recombination of the B and C excitons are allowed in the polarization configuration and forbidden in the polarization configuration, which is in contrast to the A exciton recombination that is allowed mainly in the polarization configuration and almost prohibited in the polarization configuration. According to Hopfield’s quasicubic model for WZ crystals, 

excitonic emission energies and valence band splitting parameters are related by

\[ E_\text{c} = E_\text{p} + \Delta E_{\text{V}} + \Delta E_{\text{C}} \]

Using the binding energy as that of the -FX transition peak in stress-free AlN, it is about 199 meV higher than the A-exciton peak at 6.050 eV. Therefore, based on the calculations, observed spectral peak positions and relative emission intensities in two different polarization orientations, we assign the emission peaks at 6.249 and 6.262 eV to the B and C exciton recombination, respectively. These two emission bands have not been previously observed by direct PL measurements. We believe that improved crystalline quality of AlN epilayers makes their observations possible.

A previous optical reflectance measurement revealed a spectral peak position at about 6.029 eV for the A-FX transition in AlN bulk crystals, which matches perfectly with that in AlN homo-epilayers obtained by PL measurements and represents the A-FX transition peak in stress-free AlN. It was not possible to fully resolve the peak positions of B- and C-exciton transitions by the optical reflectance measurement but careful fitting suggested positions at 6.243 and 6.268 eV, respectively. The A- and B-exciton emission peaks observed here (in a 4 μm thick AlN/Al₂O₃ epilayer) are blueshifted by 21 and 6 meV, respectively, with respect to the stress-free AlN due to a compressive strain, while a blueshift for the C-exciton transition is absent based on this optical reflectance measurement. A separate optical reflectance/transmission measurement on AlN with various crystal orientations revealed that the A, B, and C excitons have transition energies of 6.025, 6.243, and 6.257 eV in stress-free AlN, which implies that the A, B, and C exciton emission lines observed here (in a 4 μm thick AlN/Al₂O₃ epilayer) are blueshifted by 25, 6, and 5 meV, respectively, with respect to the stress-free AlN due to a compressive strain. The results seem to suggest that the effects of strain on B and C valence bands are less pronounced than that on the A valence band. However, the effects of strain on B- and C-valence bands are still ambiguous at this point. We are unable to deduce the binding energies of the B and C excitons in AlN based on the present experimental data. However, excitons associated with the A, B, and C valence bands have almost the same binding energies in GaN. Therefore, we assume that the B and C excitons in AlN have the same binding energy as that of the A exciton. This gives the band gap of AlN to be (6.249+0.080)=6.329 eV and (6.262 +0.080)=6.342 eV for the B and C valence bands, respectively.

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\[ E_\text{c} = E_\text{p} + \Delta E_{\text{V}} + \Delta E_{\text{C}} \]
which seems reasonable. Typically, transitions involving tensile of these two emission lines are relatively weak, of the reported experimental and calculated values. The in—

Valence bands related to excitonic emissions at higher energy positions of 6.249 and 6.262 eV are polarized in the $E \perp c$ direction. From these results, the crystal-field and spin-orbit splitting parameters are deduced, which agree well with previous reported results. We believe that the present results provide a more coherent picture for the valence band structure of the WZ AlN.

In summary, we have investigated the valence band structure of AlN near the $\Gamma$ point by polarization resolved deep UV PL measurements. Three different emission lines have been observed. As expected, the $A$ valence band related excitonic emission at 6.050 eV with $E \parallel c$ polarization dominates the spectrum. The observed $B$ and $C$ valence bands related excitonic emissions at higher energy positions of 6.249 and 6.262 eV are polarized in the $E \perp c$ direction.

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TABLE I. Theoretically calculated and experimentally observed values of spin-orbit splitting parameter ($\Delta_{SO}$), crystal-field splitting parameter ($\Delta_{CR}$), and $E_{AB}$, $E_{BC}$, energy spacing between the $A$ and $B$ valence bands ($E_{AB}$), and the $B$ and $C$ valence bands ($E_{BC}$) in WZ AlN.

<table>
<thead>
<tr>
<th>$\Delta_{SO}$ (meV)</th>
<th>$\Delta_{CR}$ (meV)</th>
<th>$\Delta_{EAB}$ (meV)</th>
<th>$\Delta_{EBC}$ (meV)</th>
<th>Notes</th>
</tr>
</thead>
<tbody>
<tr>
<td>-219</td>
<td>213</td>
<td>13</td>
<td>13</td>
<td>Calc.</td>
</tr>
<tr>
<td>19</td>
<td>-224</td>
<td>19</td>
<td>19</td>
<td>Calc.</td>
</tr>
<tr>
<td>$E_{A}=5.981$ (5.985) eV</td>
<td>$E_{B}=6.22$ eV</td>
<td>$E_{C}=6.23$ eV</td>
<td>$E_{C}=6.024$ eV</td>
<td>Calc.</td>
</tr>
<tr>
<td>237</td>
<td>234</td>
<td>25</td>
<td>25</td>
<td>OR, m-face bulk AlN</td>
</tr>
<tr>
<td>20</td>
<td>-206</td>
<td>199</td>
<td>13</td>
<td>This work, AlN/Al$_2$O$_3$</td>
</tr>
</tbody>
</table>

Calc.: calculation, OR: optical reflectivity, CL: cathodoluminescence $E_A$, $E_B$, $E_C$: emission energies corresponding to the $A$, $B$, and $C$ valence bands.

References: